

GEMOLOGICAL INSTITUTE

ELECTRONIC COPY

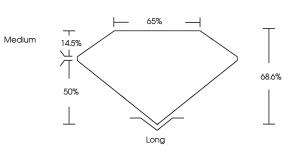
LABORATORY GROWN DIAMOND REPORT

PROPORTIONS

| April 29, 2024 | | | | |
|--------------------------------|--------------------------|--|--|--|
| IGI Report Number | LG631472548 | | | |
| Description | LABORATORY GROWN DIAMOND | | | |
| Shape and Cutting Style | EMERALD CUT | | | |
| Measurements | 7.33 X 5.41 X 3.71 MM | | | |
| GRADING RESULTS | | | | |
| Carat Weight | 1.43 CARAT | | | |
| Color Grade | 빈더집인더군 | | | |
| Clarity Grade | VS 1 | | | |
| ADDITIONAL GRADING INFORMATION | | | | |
| Polish | EXCELLENT | | | |

| Polish | EXCELLENT |
|----------------|------------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | 1671 LG631472548 |

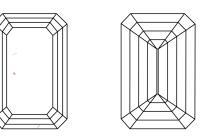
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa



LG631472548

Report verification at igi.org

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics. 1691 LG631472548

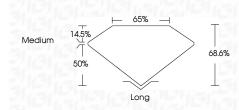
Sample Image Used

COLOR

| D E F | GHIJ | Faint | Very Light | Light |
|------------------------|--|---------------------------|----------------------|------------|
| CLARITY | VVS ¹⁻² | VS ¹⁻² | SI ¹⁻² | 10 |
| Internally Flawless | Very Very Slightly Included | Very Slightly Included | Slightly Included | Included |
| | | GEMOLO | | |
| | | | | |
| 0 | IGI 2020, International Ge | | | FD - 10 20 |
| | ioi 2020, intenditorial Ge | | 10 | FD - 10 20 |
| | THIS DOCUMENT WAS PRODUCED W BACKGROUND DESIGNS, HOLOGRAM | | | |

April 29, 2024

| April 27, 2024 | |
|-------------------------|-----------------------|
| IGI Report Number | LG631472548 |
| Description LABC | DRATORY GROWN DIAMOND |
| Shape and Cutting Style | EMERALD CUT |
| Measurements | 7.33 X 5.41 X 3.71 MM |
| GRADING RESULTS | |
| Carat Weight | 1.43 CARAT |
| Color Grade | н |
| Clarity Grade | VS 1 |
| | |
| | |



ADDITIONAL GRADING INFORMATION

| Polish | EXCELLENT |
|--|----------------------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | 低到 LG631472548 |
| Comments: This Laboratory created by Chemical Vapo process and may include p Type IIa | or Deposition (CVD) growth |



